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## (I) Plasma assisted oxidation of H<sub>2</sub> mixtures: from physics to chemistry

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For the past decades, plasma technology has been widely investigated to advance energy and environmental applications. The main focus of this research revolves either around developing new or enhancing existing reforming, combustion, and remediation processes. Nevertheless, due to the complex physicochemical nature of non-thermal plasma's, most of the experimental findings still await a full understanding. Here, we present our recent progress in developing and validating a temperature dependent plasma-chemical kinetic model for H/O/N systems. Our aim is to establish a foundation for low-temperature plasma assisted ignition as well as high-temperature plasma catalysis and reforming processes.

We performed an experimental and numerical study for the plasma assisted low-temperature oxidation of H<sub>2</sub> for undiluted H<sub>2</sub>/O<sub>2</sub> mixtures. We employed a temperature controlled dielectric barrier discharge reactor and developed a reaction mechanism as well as a zero-dimensional plasma-chemical kinetic model (KAUSTKin). Through systematically varying the gas temperature and discharge power, we found non-linear oxidation behavior highlighting a Negative Temperature Coefficient (NTC)-like trend in the temperature range of 600  $\leq$   $T_g \leq$  750 K. The simulations could successfully attribute these observations to a combination of physical and chemical effects. The unexpected non-linear change in the breakdown voltage and subsequent reduced field (*E/N*) with varying temperature was the dominant contributor for the nonlinear oxidation characteristics; at the same time, both the O<sub>3</sub> and HO<sub>2</sub> chemistry played a key role.

Our findings show the importance of both the plasma-physical characteristics and the subsequent plasmachemical kinetics to properly predict plasma processes. Furthermore, the distinct effects of E/N and  $T_g$  on the chemistry highlight how electrical discharges provide two ways of controlling the plasma reactions; by affecting the electron induced chemistry (governed by the physical properties of the discharge) and the thermally induced chemistry, respectively. The outcome of this work will serve as a basic building block for future oxidation and reforming studies of CH<sub>4</sub> and higher hydrocarbons.

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